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## Solid state reaction between zirconium and silicon carbide at elevated temperatures

*Thursday, 12 July 2012 17:30 (2 hours)*

### Abstract content <br> &nbsp; (Max 300 words)

The solid state reactions between a Zr thin film (150nm) and a single crystalline bulk 6H-SiC substrate induced by vacuum annealing at temperatures of 600 – 800 °C for durations of 30, 45 and 60 minutes, were investigated by 1.6 MeV He<sup>+</sup> backscattering spectrometry, X-ray diffraction and secondary electron microscopy.

Zr was found not to react with SiC at a temperature of 600 °C. The backscattered spectra were simulated using RUMP and the as-deposited spectra fit with the 600 °C annealed spectra thus showing there were no reactions taking place. At higher temperatures, Zr reacts with the SiC substrate and forms a mixed layer of Zr carbide (ZrC<sub>x</sub>) and Zr silicide (Zr<sub>2</sub>Si) at annealing temperatures above 700°C. The formation of these phases was also confirmed by XRD.

### Apply to be<br> consider for a student <br> &nbsp; award (Yes / No)?

yes

### Level for award<br>&nbsp;(Hons, MSc, <br> &nbsp; PhD)?

PhD

### Main supervisor (name and email)<br>and his / her institution

Prof. Chris Theron

### Would you like to <br> submit a short paper <br> for the Conference <br> Proceedings (Yes / No)?

No

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**Session Classification:** Poster Session

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